

## **ECE 340: Semiconductor Electronics**

# **Review: Chapter 5 and 8**

Solid State Electronic Devices (Streetman): § 5, § 8

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# Outline

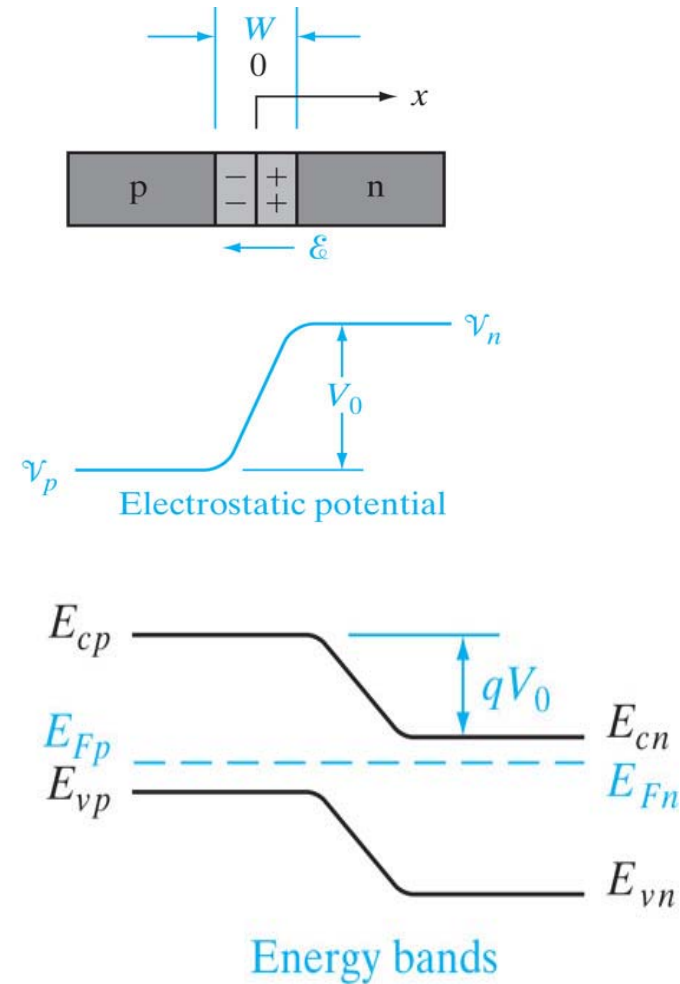
- Chapter 5: junctions
  - Equilibrium Condition
  - Forward- and reverse-biased junctions; steady state conditions
  - Reverse-bias breakdown
  - Transient and a-c conditions
- Chapter 8: optoelectronic devices
  - Solar Cell
  - Photodetector
  - Light-Emitting Diodes
  - Semiconductor Lasers

# Form PN junction

Isolated n and p region



pn junction at equilibrium

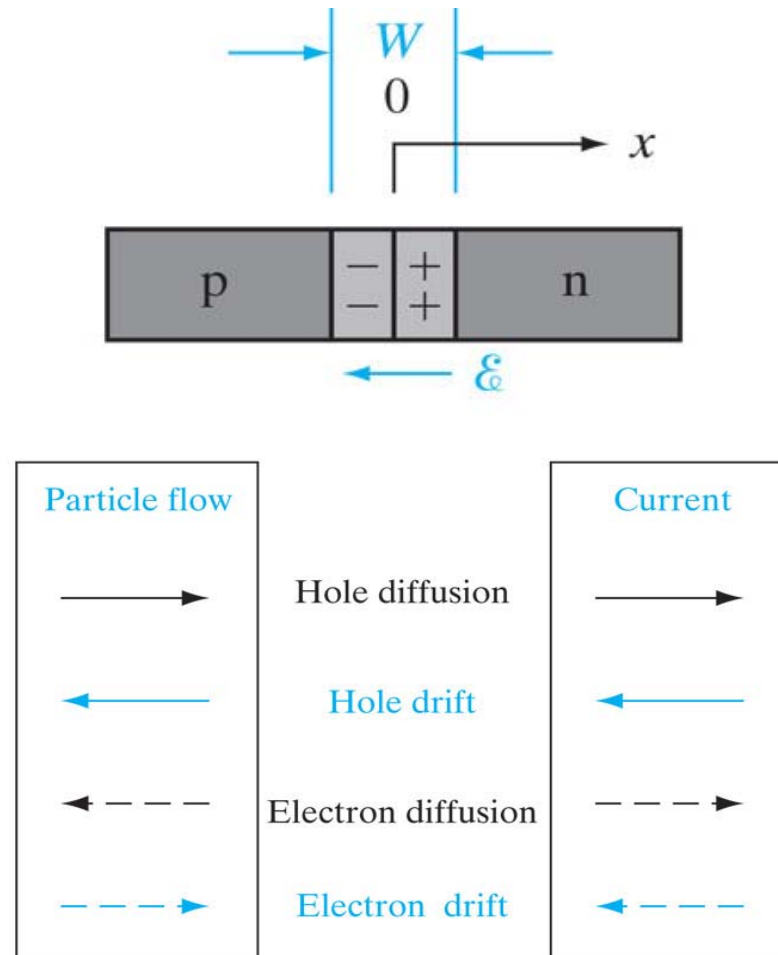


Built-in potential

$$V_0 = \frac{kT}{q} \ln \left( \frac{N_a N_d}{n_i^2} \right)$$

$$V_0 = \phi_n + \phi_p$$

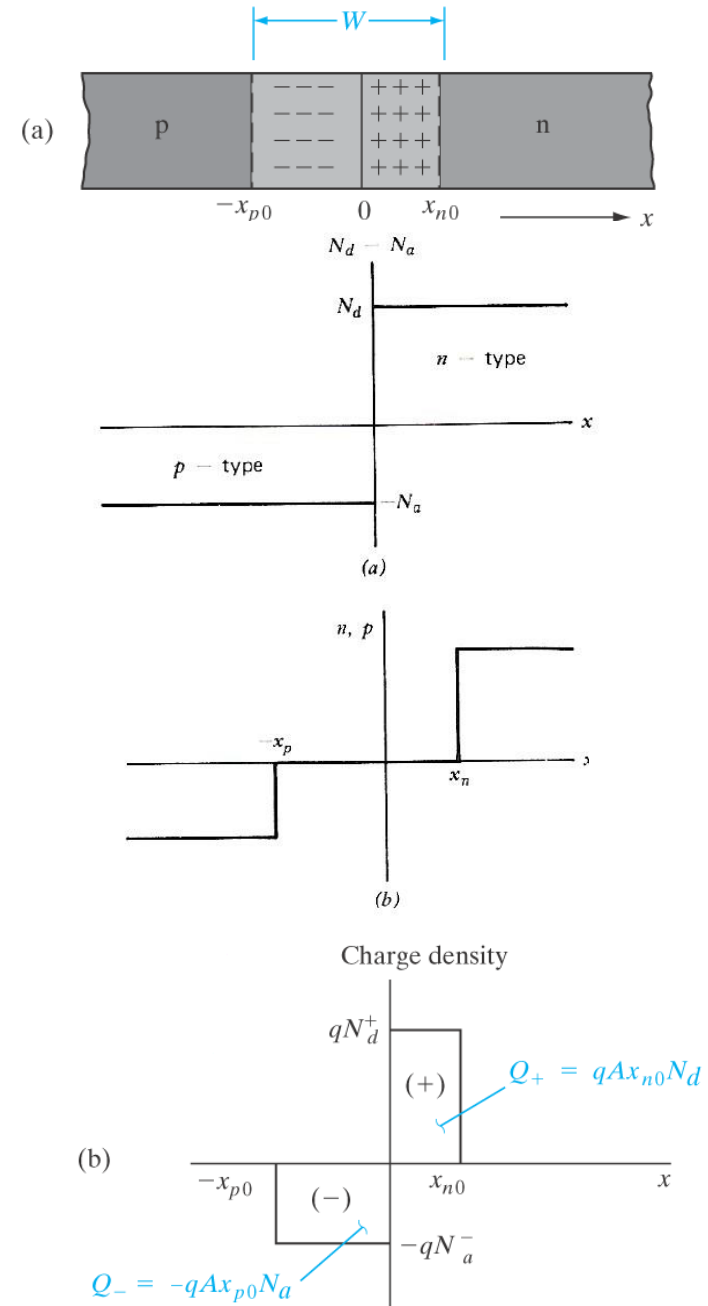
# pn junction at equilibrium carrier flow



# Space charge at a junction

- Depletion approximation:  
assumption of carrier  
depletion within  $W$  and  
neutrality outside  $W$ .

$$x_{p0}N_a = x_{n0}N_d$$



# Electric field

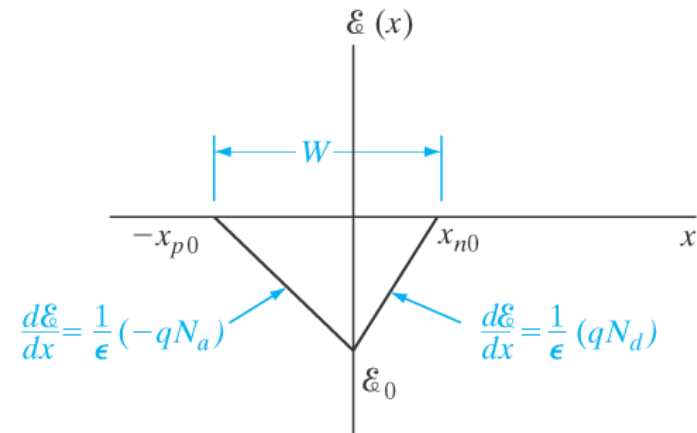
- Poisson's equation:

$$\frac{d\mathcal{E}(x)}{dx} = \frac{q}{\epsilon} (p - n + N_d^+ - N_a^-)$$

- If neglect the contributions of carriers in space charge, and assume complete ionization of impurities:

$$\frac{d\mathcal{E}(x)}{dx} = \frac{q}{\epsilon} N_d \quad 0 < x < x_{n0}$$

$$\frac{d\mathcal{E}(x)}{dx} = -\frac{q}{\epsilon} N_a \quad -x_{p0} < x < 0$$



# Built-in electric field

Built-in field:

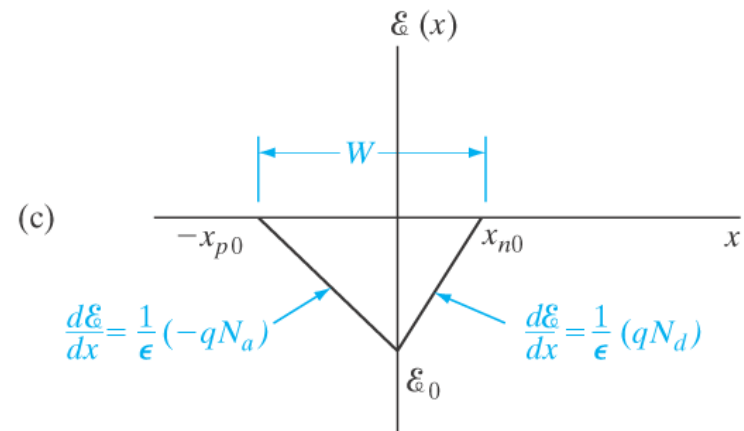
$$\mathcal{E}(x) = -\frac{qN_d}{\epsilon}(x_{n0} - x) \quad 0 < x < x_{n0}$$

$$\mathcal{E}(x) = -\frac{qN_a}{\epsilon}(x_{p0} + x) \quad -x_{p0} < x < 0$$

- The maximum electric field located at the interface of n and p junction ( $x=0$ ):

$$\Rightarrow \mathcal{E}_0 = -\frac{q}{\epsilon} N_d x_{n0} = -\frac{q}{\epsilon} N_a x_{p0}$$

**maximum electric field**



# Potential

$$\frac{dV(x)}{dx} = -\mathcal{E}(x)$$

- Potential variation across the junction:

$$V(x) = \phi_n - \frac{qN_d}{2\epsilon_s}(x_n - x)^2 \quad 0 < x < x_{n0}$$

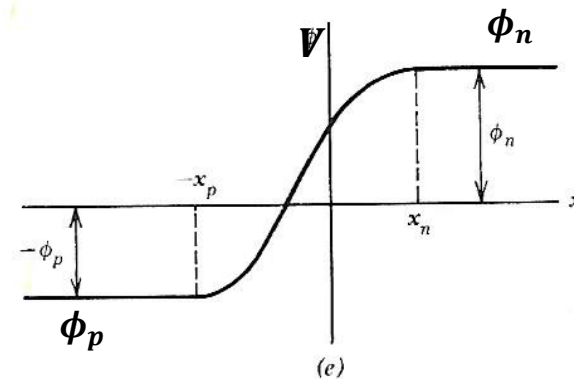
$$V(x) = \phi_p - \frac{qN_a}{2\epsilon_s}(x + x_p)^2 \quad -x_{p0} < x < 0$$

where  $\phi_n = \frac{kT}{q} \ln \frac{N_d}{n_i}$

$$\phi_p = \frac{kT}{q} \ln \frac{N_a}{n_i}$$

- Built-in variation:

$$V_0 = \phi_n + \phi_p = \frac{kT}{q} \ln \frac{N_d N_a}{n_i}$$





# Depletion width and penetration depth

$$V_0 = -\frac{1}{2} \epsilon_0 W = \frac{1}{2} \frac{q}{\epsilon} N_d x_{n0} W$$

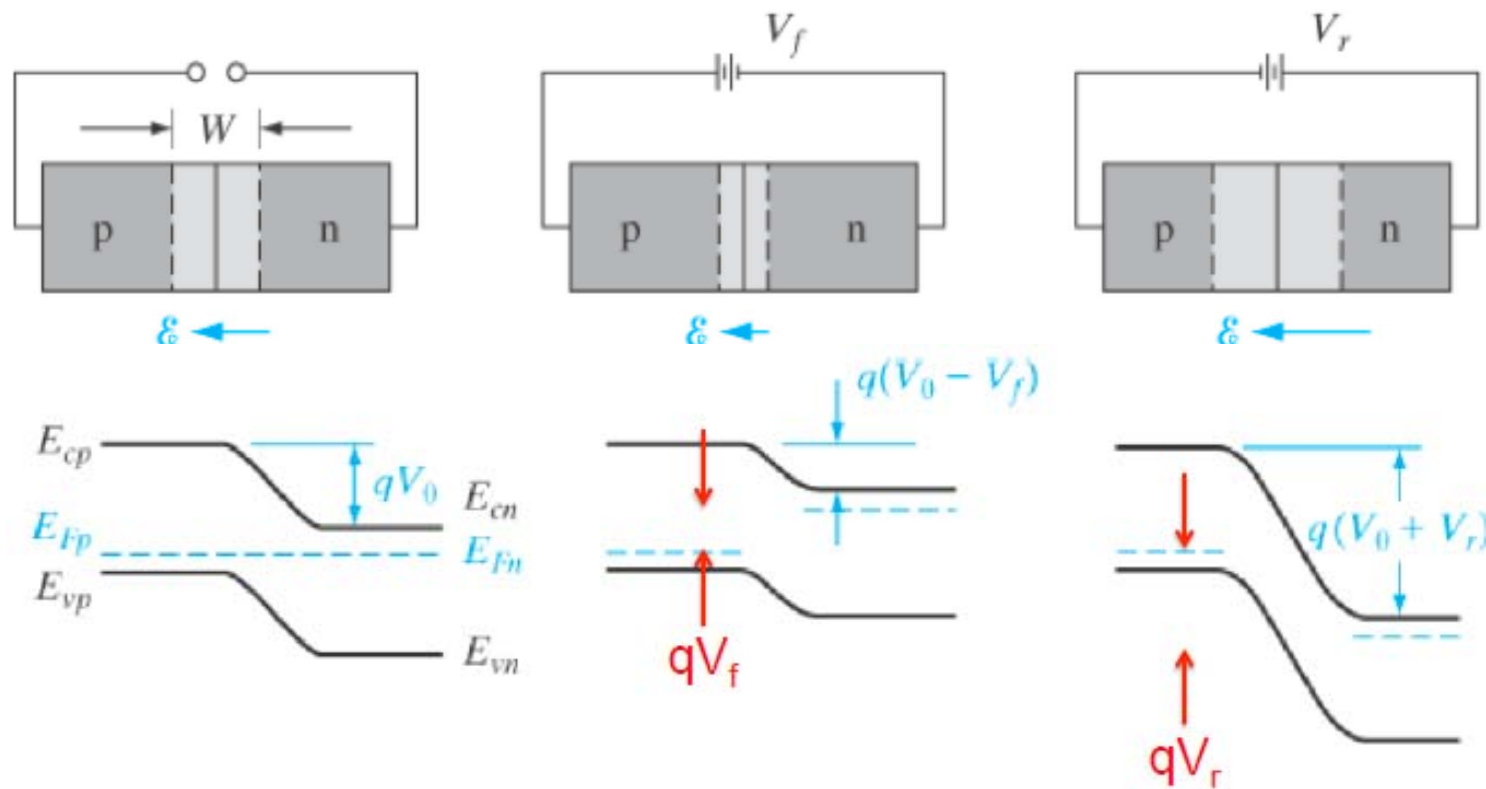
⇒ Depletion width

$$W = \left[ \frac{2\epsilon V_0}{q} \left( \frac{N_a + N_d}{N_a N_d} \right) \right]^{1/2} = \left[ \frac{2\epsilon V_0}{q} \left( \frac{1}{N_d} + \frac{1}{N_a} \right) \right]^{1/2}$$

penetration depth

$$x_{p0} = W \frac{N_d}{N_a + N_d}$$
$$x_{n0} = W \frac{N_a}{N_a + N_d}$$

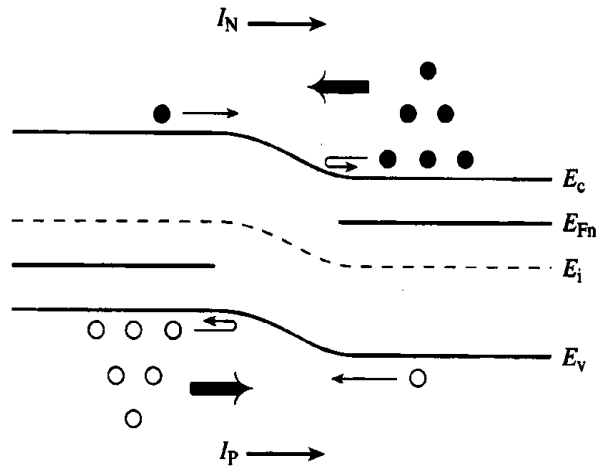
# Bias, depletion width, and quasi-Fermi level



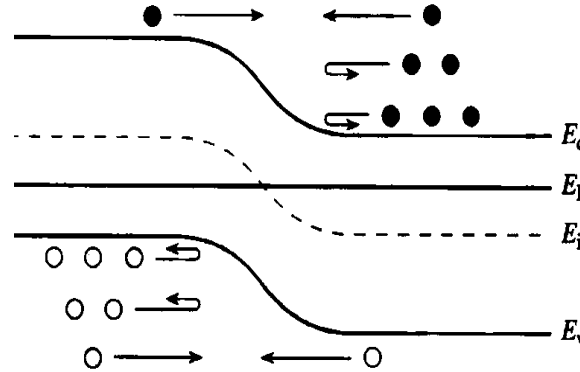
$$W = \sqrt{\frac{2\epsilon(V_0 - V_a)}{q} \left( \frac{1}{N_d} + \frac{1}{N_a} \right)}$$

# Current flow in pn junction:

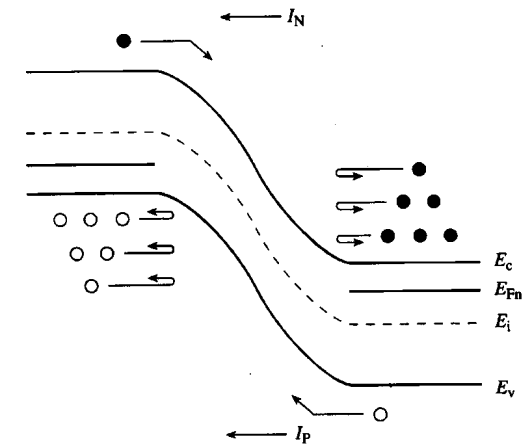
**Forward bias**



**Equilibrium**



**Reverse bias**



Hole diffusion

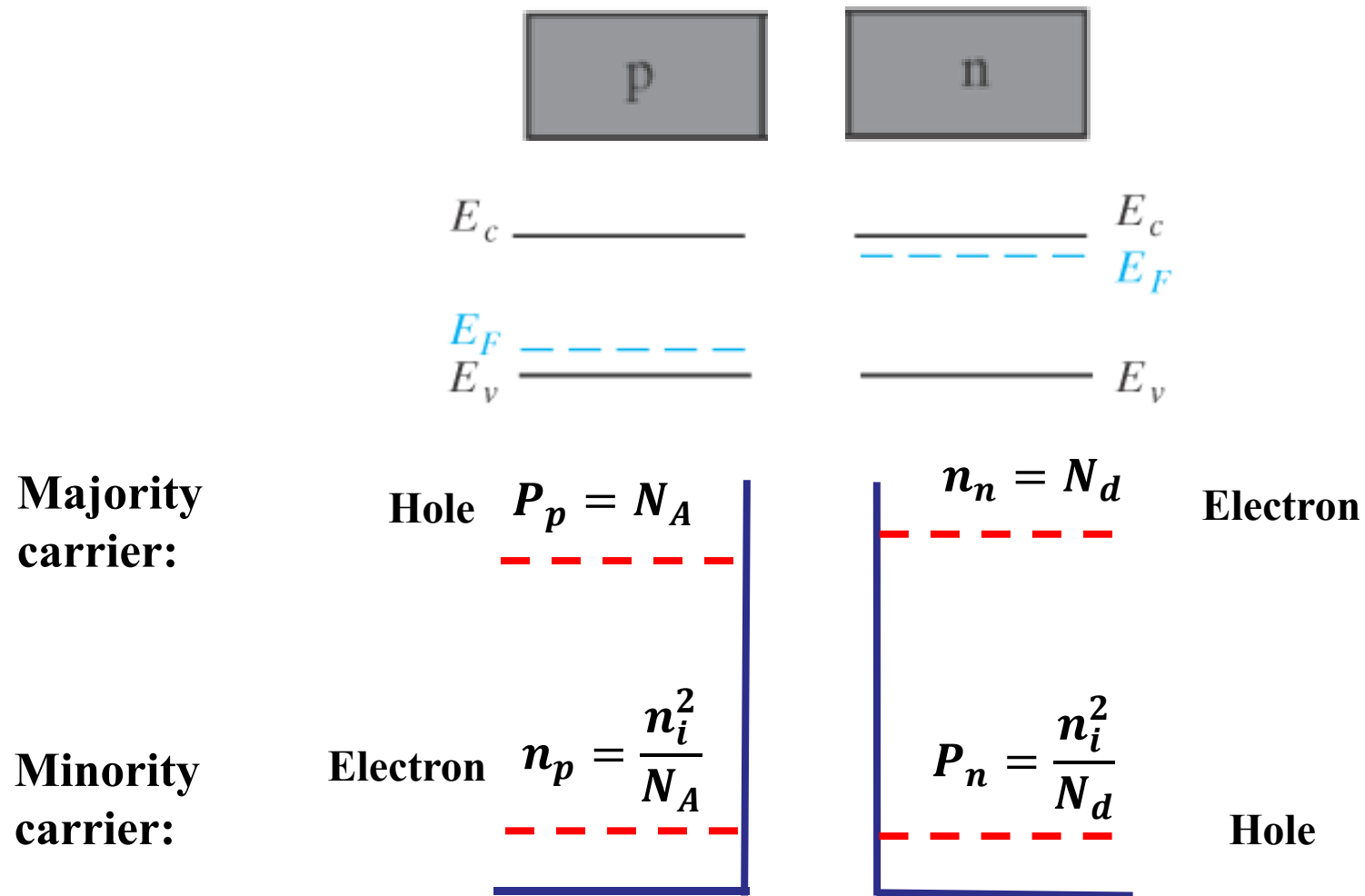
Hole drift

electron diffusion

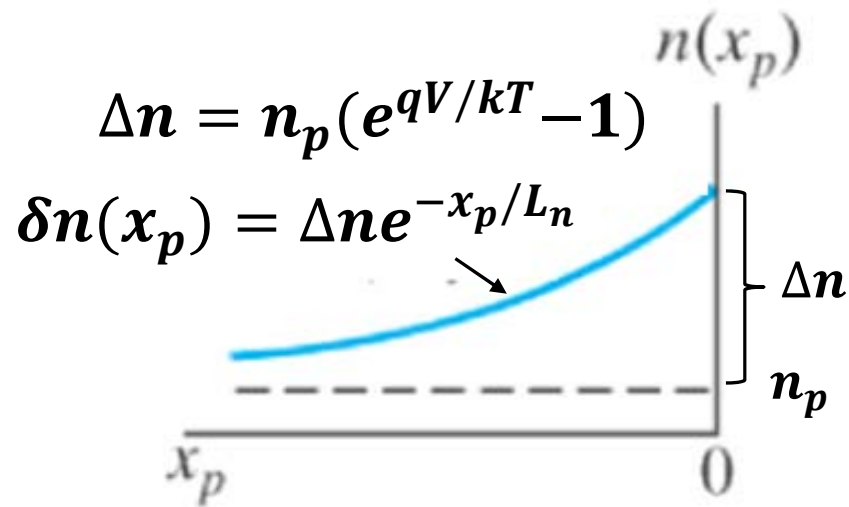
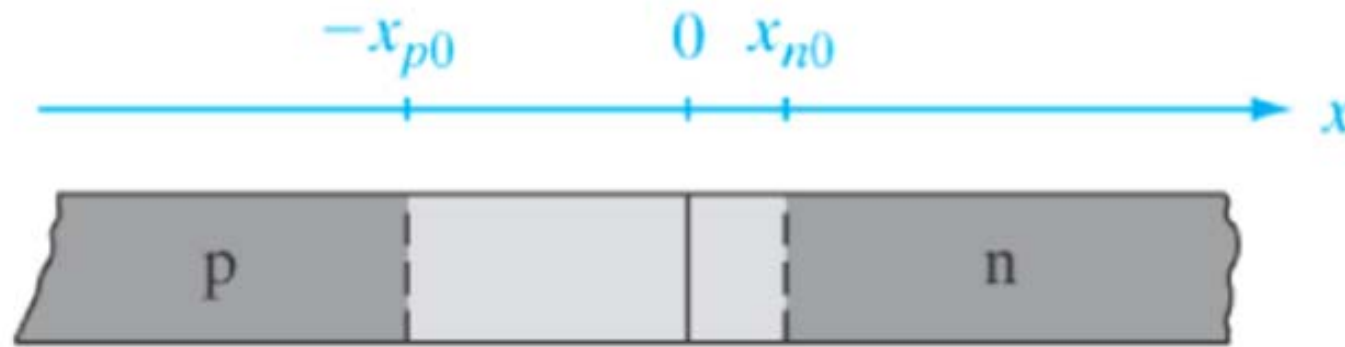
electron drift

	Particle flow	Current
(1)	→	→
(2)	←	←
(3)	←	→
(4)	→	←

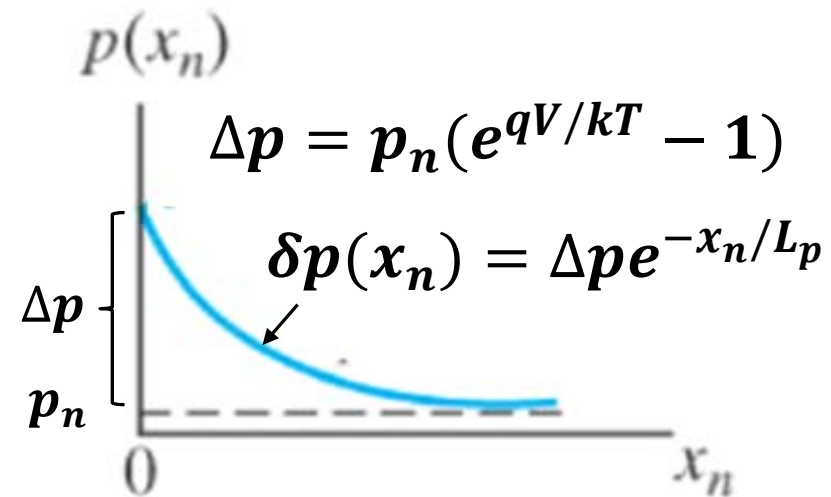
# P and n region before contact



# Forward bias, minority carrier diffusion

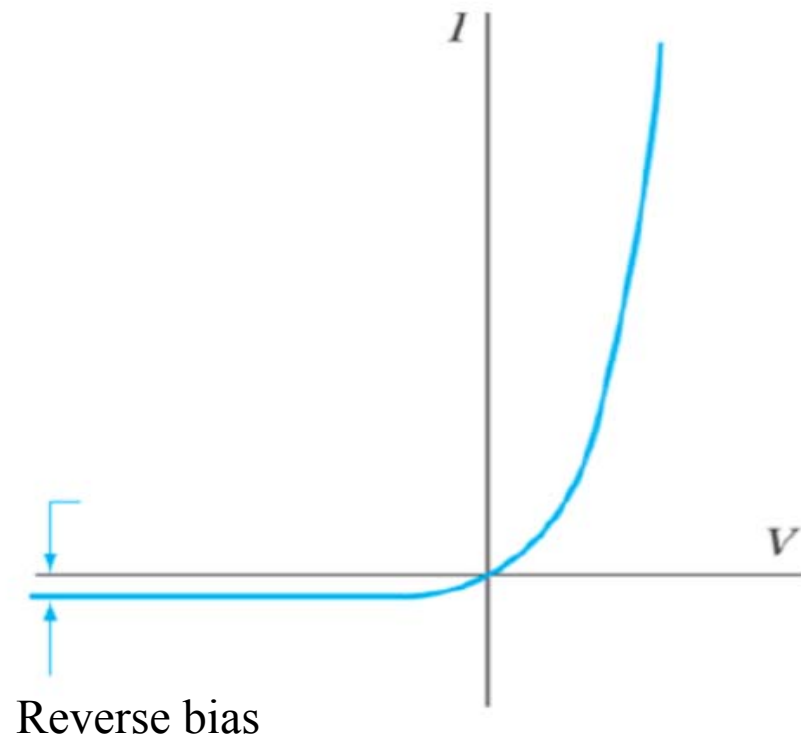


$$I_n(x_p = 0) = -qA \frac{D_n}{L_n} n_p (e^{qV/kT} - 1)$$



$$I_p(x_n = 0) = qA \frac{D_p}{L_p} p_n (e^{qV/kT} - 1)$$

# Diode equation: various scenarios



$$V = -V_r$$
$$I \approx -I_0$$

$$I = I_0 (e^{qV/kT} - 1)$$

$$\text{where } I_0 = qA \left( \frac{D_p}{L_p} p_n + \frac{D_n}{L_n} n_p \right)$$

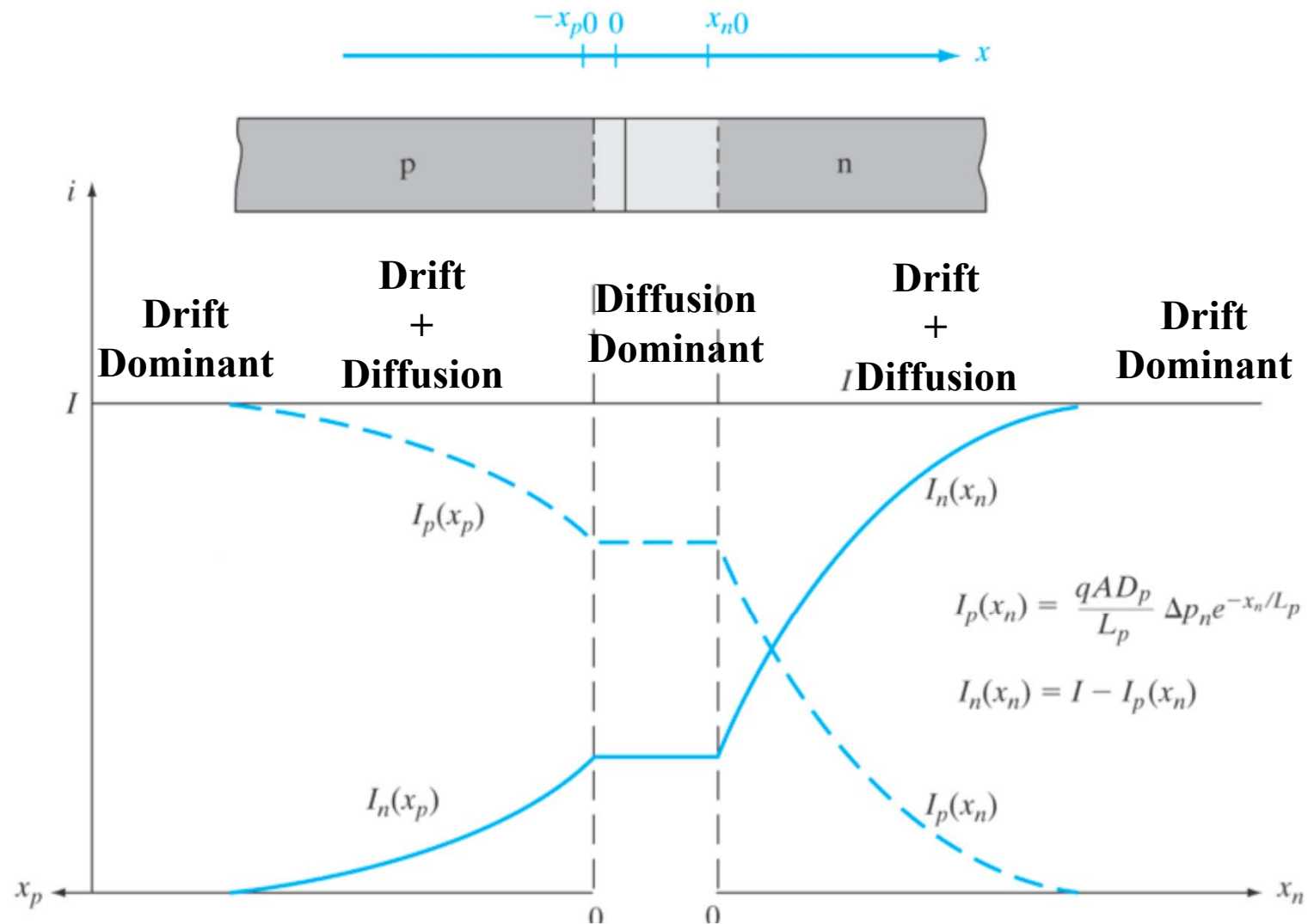
(a) p<sup>+</sup>-n junction:  $p_n \gg n_p$

$$I_0 = qA \frac{D_p}{L_p} p_n$$

(b) p-n<sup>+</sup> junction:  $p_n \ll n_p$

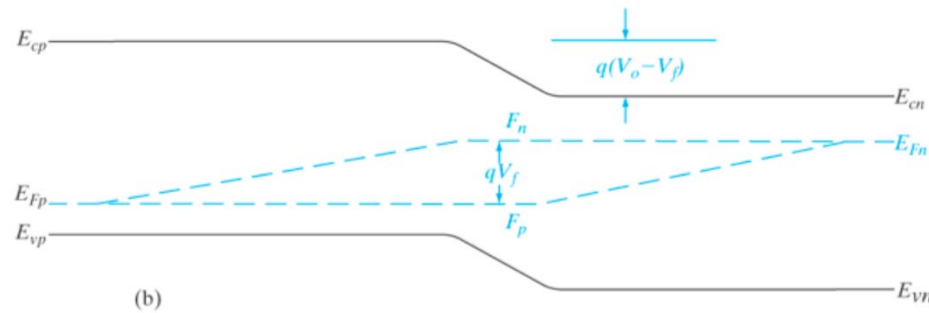
$$I_0 = qA \frac{D_n}{L_n} n_p$$

# Drift and diffusion in forward bias



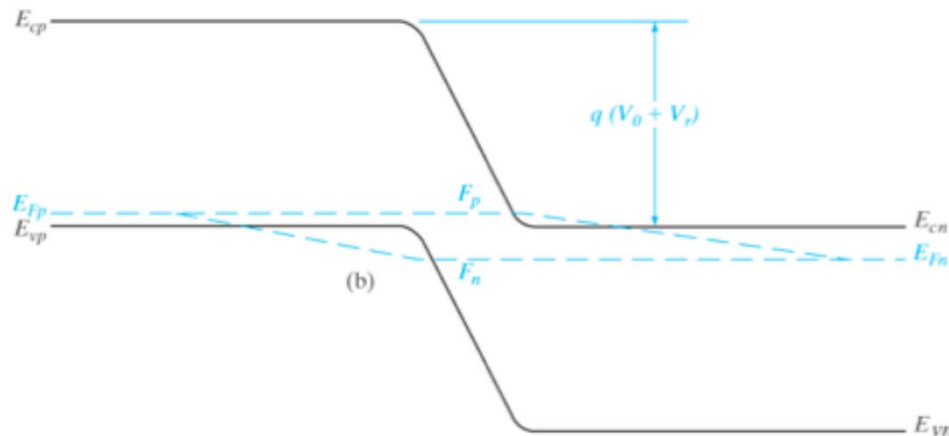
# Quasi-Fermi level

## Forward bias



$$pn = n_i^2 e^{(qV/kT)}$$

## Reverse bias

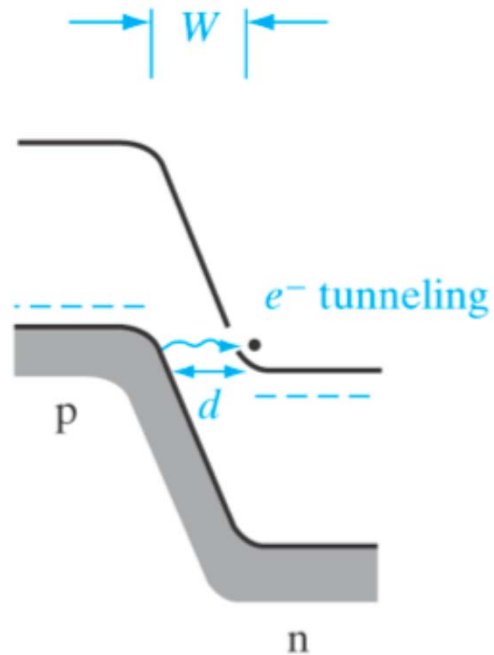


$$pn = n_i^2 e^{(F_n - F_p)/kT} \approx 0$$



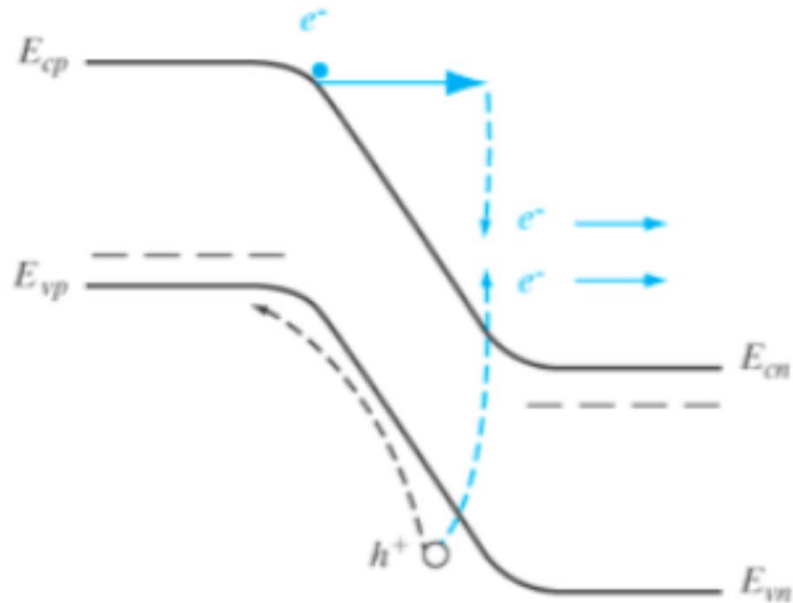
# Zener breakdown

## Zener breakdown



- High doping
- Occurs at low voltages

## Avalanche breakdown

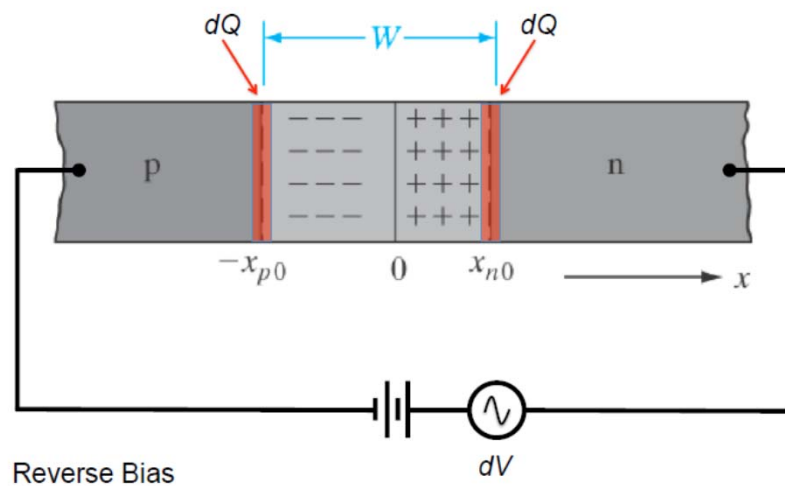


- Low doping
- Occurs at high voltages

# pn junction capacitance

## Junction capacitance

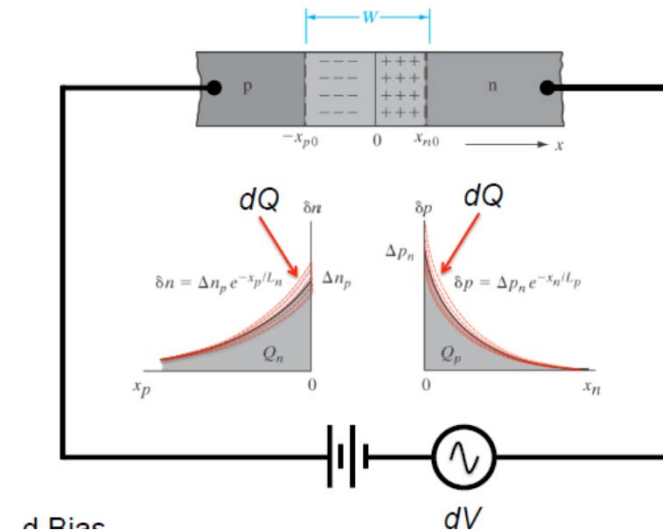
### Reverse bias



$$C_j = A \sqrt{\frac{q\epsilon}{2(V_0 - V)} \frac{N_d N_a}{N_a + N_d}} = \frac{\epsilon A}{W}$$

## Diffusion capacitance (Charge storage capacitance)

### Forward bias

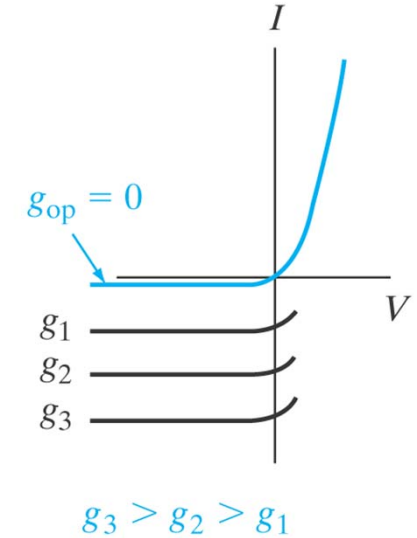
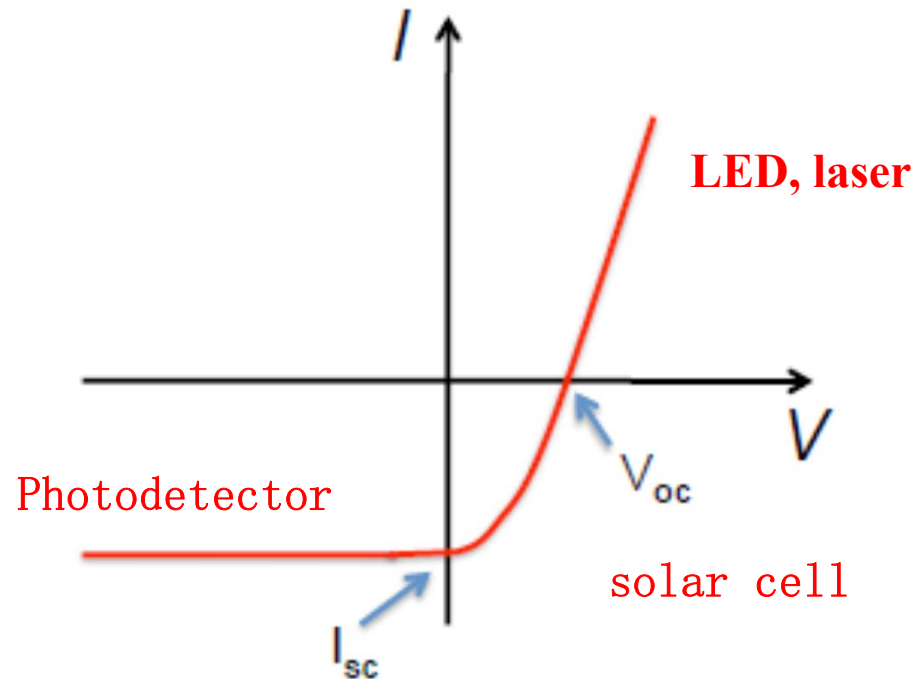


$$C_s = \frac{dQ_p}{dV} \approx \frac{q}{kT} Q_p$$

# Current in an illuminated junction

- The total reverse current with illumination

$$I = I_{th} (e^{qV/kT} - 1) - I_{op}$$



# Solar cell figure-of-merit

- Maximum power :

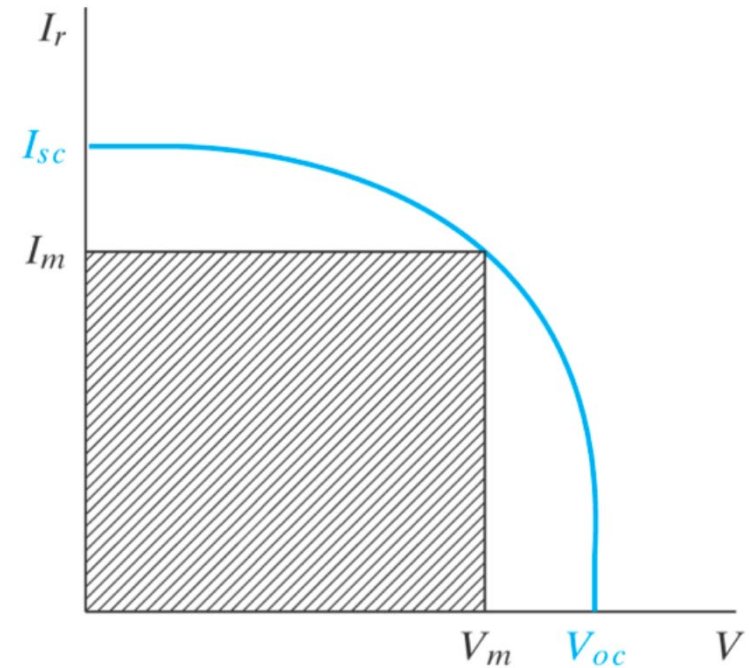
$$P_m = I_m V_m$$

- Fill factor:

$$FF = \frac{I_m V_m}{I_{sc} V_{oc}}$$

- Efficiency:

$$\eta = \frac{P_m}{P_{in}} = \frac{I_{sc} V_{oc} FF}{P_{in}}$$



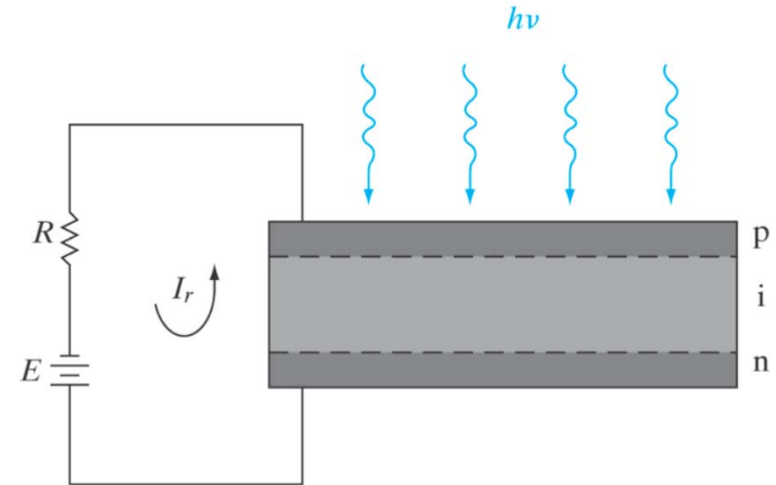
# Figure of merit for photodetector

- Internal quantum efficiency:

$$\eta_{in} = \frac{EHP}{P_{op}/h\nu}$$

- External quantum efficiency:

$$\eta_{ext} = \frac{J_{op}/q}{P_{op}/h\nu}$$



- Maximum response frequency

$$f_{max} \approx \frac{1}{\text{transit time}} \approx \frac{1}{W/V_{sat}} = \frac{V_{sat}}{W}$$

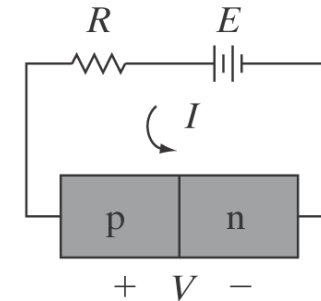
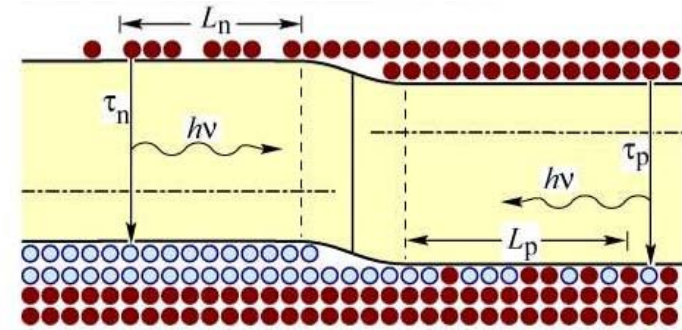
- Responsivity:

$$R = \frac{I_{op}}{P_{op}} = \frac{q\eta_{ext}}{h\nu}$$

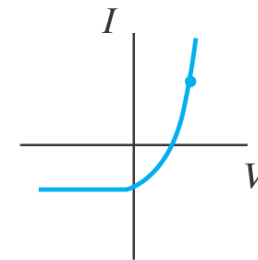
# Light-emitting diode

- Forward bias pn junction
- Minority & majority carriers recombine and emit light
- Operate in 1<sup>st</sup> quadrant
- Emitted light energy

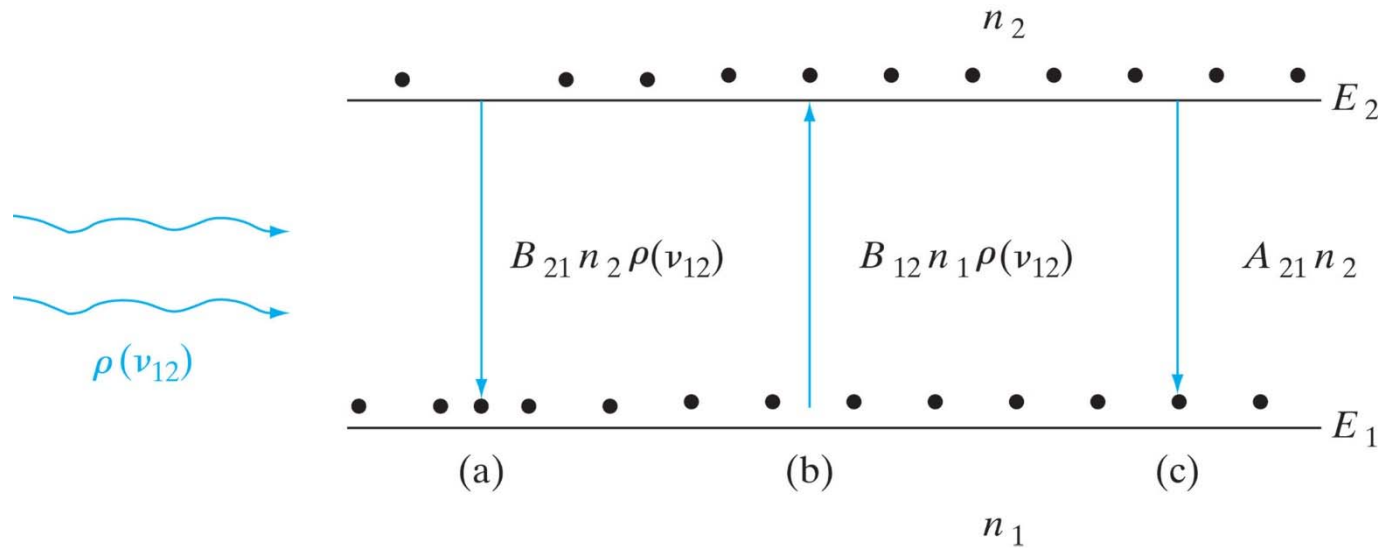
$$h\nu_{out} = E_g$$



1st quadrant



# Steady state condition



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In steady state, the emission rates must balance the absorption rate:

$$\left. \frac{dn_2}{dt} \right|_{abs} + \left. \frac{dn_2}{dt} \right|_{spon} + \left. \frac{dn_2}{dt} \right|_{stim} = 0 \quad \text{or}$$

$$B_{12} n_1 \rho(v_{12}) = A_{12} n_2 + B_{21} n_2 \rho(v_{12})$$

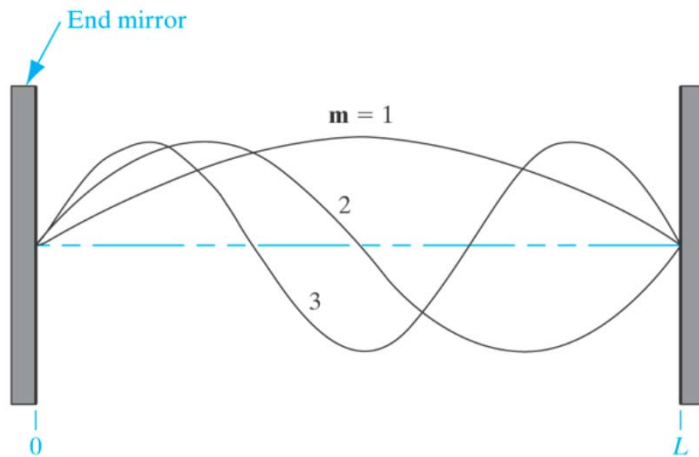
Absorption
spontaneous emission
stimulated emission

# Laser:

## Conditions for lasing:

1. 
$$\frac{\text{Stimulated emission rate}}{\text{Spontaneous emission rate}} = \frac{B_{21}}{A_{12}} \rho(\nu_{12})$$

A large photon field energy density enhances the stimulated emission rate → use optical resonant cavity



The length of the cavity for stimulated emission must be:

$$L = \frac{m\lambda}{2} = \frac{m\lambda_0}{2n}$$

$\lambda$ : Photon wavelength within the laser material

$\lambda_0$ : output light wavelength in the atmosphere

$n$ : index of refraction of the laser material

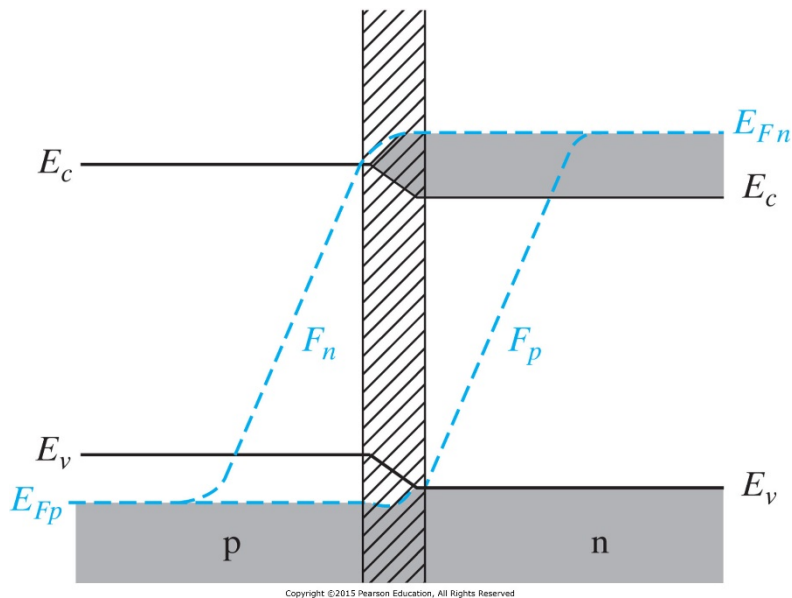


# Laser

## Conditions for lasing:

$$2. \quad \frac{\text{Stimulated emission rate}}{\text{absorption rate}} = \frac{B_{21}n_2\rho(\nu_{12})}{B_{12}n_1\rho(\nu_{12})} = \frac{B_{21}n_2}{B_{12}n_1}$$

For stimulated emission to exceed absorption,  $n_2 > n_1$ ,  $\rightarrow$  need population inversion (negative temperature)



Lasing condition (population inversion):

$$F_n - F_p > h\nu$$

For band-edge transitions:

$$F_n - F_p > E_g$$